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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/747,844 12/21/2000		Rod Kistler	LAM2P220C	4383	
25920 7.	590 07/16/2002				
	PENILLA, LLP		EXAMINER		
710 LAKEWA SUITE 170			MORGAN, EILEEN P		
SUNNYVALE	CA 94085		ART UNIT	PAPER NUMBER	1
			3723		

Please find below and/or attached an Office communication concerning this application or proceeding.

# Office Action Summary

Application No. 09/747,844

Applicant(s)

Kistler et al.

Examiner

Morgan

Art Unit **3723** 



The MAILING DATE of this communication appears on the cover sheet with the correspondence address									
	or Reply	_	_						
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be evailable under the provisions of 37 CFR 1.136 (a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.									
- If NO p - Failure - Any re	<ul> <li>If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.</li> <li>If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.</li> <li>Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).</li> <li>Amy reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).</li> </ul>								
Status									
1) 💢	Responsive to communication(s) filed on Jan 28, 20	002		<u> </u>					
2a) ☐ This action is <b>FINAL</b> . 2b) ☒ This action is non-final									
3) 🗆	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11; 453 O.G. 213.								
Disposi	tion of Claims								
4) 💢	Claim(s) <u>1-28</u>			is/are pending in the application.					
4	a) Of the above, claim(s)			is/are withdrawn from consideration.					
5) 🗆	Claim(s)		. <u></u> .	is/are allowed.					
6) 💢	Claim(s) <u>1-28</u>			is/are rejected.					
7) 🗆	Claim(s)			is/are objected to.					
8) 🗆	Claims	are	subject 1	to restriction and/or election requirement.					
Applica	tion Papers								
9) 🗆	The specification is objected to by the Examiner.								
10)	10)☐ The drawing(s) filed on is/are a)☐ accepted or b)☐ objected to by the Examiner.								
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).								
11)	The proposed drawing correction filed on	is:	a) 🗆 ap	proved b) $\square$ disapproved by the Examiner.					
	If approved, corrected drawings are required in reply to this Office action.								
12)	12) $\square$ The oath or declaration is objected to by the Examiner.								
Priority under 35 U.S.C. §§ 119 and 120									
13) 🗌	3) Acknowledgement is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).								
a) [	☐ All b)☐ Some* c)☐ None of:			•					
	1. $\square$ Certified copies of the priority documents hav	e been receive	d.						
	2. $\square$ Certified copies of the priority documents hav								
	<ol> <li>Copies of the certified copies of the priority do application from the International Burea ee the attached detailed Office action for a list of the</li> </ol>	au (PCT Rule 1	7.2(a)).	•					
14) ∐ a) [	Acknowledgement is made of a claim for domestic  The translation of the foreign language provisiona								
15)	Acknowledgement is made of a claim for domestic								
Attachm	•								
	tice of References Cited (PTO-892)	4) Interview Su	mmary (PTO-	413) Paper No(s)					
2) No	tice of Draftsperson's Patent Drawing Review (PTO-948)	5) Notice of Inf	ormal Patent	Application (PTO-152)					
3) 🔲 Inf	ormation Disclosure Statement(s) (PTO-1449) Paper No(s).	6) Other:							

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#### **DETAILED ACTION**

## Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless --

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claims 1-7 are rejected under 35 U.S.C. 102(b) as being anticipated by Doran-5,888,120.

Doran discloses a platen (210) with a plurality of piezoelectric elements (306-316) disposed above the platen, capable of exerting pressure on a polishing belt, wherein an electric field is used to activate the elements, the elements varying in dimension, the smaller being near the edge of the platen, wherein the elements individually activated to exert different forces, and wherein an a sacrificial material (212) is disposed above the platen for reducing wear.

#### Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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4. Claims 1-6, 8-14,17,19-23 are rejected under 35 U.S.C. 103(a) as being unpatentable over Pant et al.-5,916,012 in view of Doran.

Pant discloses the claimed invention including applying a force to a bottom side of a polishing belt wherein a platen is below a belt and a wafer is polished from above the belt, wherein the pressure on the belt vary through slits (31,41). Pant does not disclose the use of piezoelectric elements for exerting pressure. However, Doran teaches polishing a wafer by applying different pressures on the backside through the use of piezoelectric elements (306-316) which can be controlled to exert varying pressure in response to conditions and wherein the elements vary in size and are smaller near the edge. Therefore, it would have been obvious to one of ordinary skill in the art at time invention was made to substitute the pressure control means of Pant with piezoelectric elements, as taught by Doran, in order to more accurately control pressure distribution.

5. Claims 7,15,16,18, rejected under 35 U.S.C. 103(a) as being unpatentable over Pant and Doran as applied to claims above, and further in view of Tietz-6,135,859.

Pant and Doran fail to show a rolling sacrificial member. However, Tietz teaches polishing a wafer with a belt, having a platen and using a rolling supporting member (476b) member above platen for increase support and backing to belt (456b). Therefore, it would have been obvious to one of ordinary skill in the art at time invention was made to provide Pant with a rolling support member, as taught by Tietz, in order to increase support to the polishing belt.

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6. Claims 24-28 are rejected under 35 U.S.C. 103(a) as being unpatentable over Pant et al in view of Doran and Tietz.

Pant discloses the claimed invention including applying a force to a bottom side of a polishing belt wherein a platen is below a belt and a wafer is polished from above the belt, wherein the pressure on the belt vary through slits (31,41). Pant does not disclose the use of piezoelectric elements for exerting pressure or a rolling sacrificial member. However, Doran teaches polishing a wafer by applying different pressures on the backside through the use of piezoelectric elements (306-316) which can be controlled to exert varying pressure in response to conditions and wherein the elements vary in size and are smaller near the edge. Therefore, it would have been obvious to one of ordinary skill in the art at time invention was made to substitute the pressure control means of Pant with piezoelectric elements, as taught by Doran, in order to more accurately control pressure distribution. In regard to the sacrificial member, Tietz teaches polishing a wafer with a belt, having a platen and using a rolling supporting member (476b) member above platen for increase support and backing to belt (456b). Therefore, it would have been obvious to one of ordinary skill in the art at time invention was made to provide Pant with a rolling support member, as taught by Tietz, in order to increase support to the polishing belt.

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### Response to Arguments

7. Applicant's arguments with respect to claims 1-7 have been considered but are moot in view of the new ground(s) of rejection.

In regard to arguments to the Pant and Dorna combination. Pant indeed discloses using varying air pressure against the back side of the polishing belt to achieve uniform polishing.

Doran is relied upon to teach the use of exerting pressure by piezoelectric elements, which are functionally equivalent to the air pressure points of Pant, and therefore, one of ordinary skill would be motivated to use a functional equivalent, such as piezoelectric elements to exert the pressure of the Pant device. On page 5, Applicant argues the combination rejection as if the claims were rejected over Doran in view of Pant, which is erroneous.

8. Any inquiry concerning this communication or earlier communications from the examiner should be directed to E. Morgan whose telephone number is (703) 308-1743.

EILEEN P. MORGAN PRIMARY EXAMINER

EM

July 15, 2002